

IFW

XA-10297

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

Mitsuhiro YANARI

Appln. No.: 10/530,403

Group Art Unit: 2872

Filed: April 7, 2005

For: OPTHALMIC LENS DESIGN METHOD, OPTHALMIC LENS  
MANUFACTURING METHOD AND COMPUTER PROGRAM

\* \* \*

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

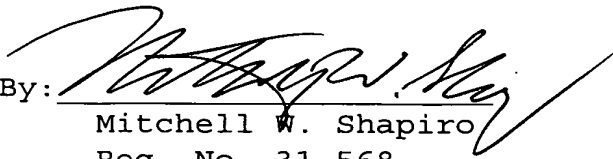
Pursuant to 37 C.F.R. § 1.56, and without any assertion  
as to materiality or prior art effect, the document listed on  
the attached Form PTO-1449 is hereby cited.

Respectfully submitted,

MWS:sjk

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By:

  
Mitchell W. Shapiro  
Reg. No. 31,568

March 23, 2007



FORM PTO-1449 INFORMATION DISCLOSURE STATEMENT LIST OF DOCUMENTS CITED BY APPLICANT				Atty. Docket No. XA-10297		Appln. No. 10/530,403	
				Applicant Mitsuhiro YANARI			
				Filing Date April 7, 2005		Group 2872	
U.S. PATENT DOCUMENTS							
Examiner Initial		Document Number	Date	Name	Class	Sub-class	Filing Date
	AA						
	AB						
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
FOREIGN PATENT DOCUMENTS							
Examiner Initial		Document Number	Date	Country	Class	Sub-class	Translation
	AJ	WO 02/088828	22/07/03	WIPO			Abstract
	AK						
	AL						
	AM						
	AN						
	AO						
OTHER (including author, title, date, pertinent pages, etc.)							
	AP						
	AQ						
Examiner				Date Considered			
EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.							